



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of: Daisuke ENDO, et al.

Serial No.: 10/564,742

Group Art Unit: 1729

Filing Date: January 17, 2006

Examiner: Jacob B. Marks

For: POSITIVE ACTIVE MATERIAL, PROCESS FOR PRODUCING THE SAME,
AND POSITIVE ELECTRODE FOR LITHIUM SECONDARY BATTERY AND
LITHIUM SECONDARY BATTERY EACH EMPLOYING THE SAME

Honorable Commissioner for Patents
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

Under the provisions of 37 CFR §1.97 through §1.98 and pursuant to applicants' duty of disclosure under 37 CFR §1.56, applicants respectfully bring the following documents cited in the Japanese Office Action dated September 6, 2011 in a counterpart foreign application and listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. Copies of the listed documents are provided herewith for the convenience of the Examiner (with English abstracts). Further, an English language translation of the Office Action is attached.

In compliance with the requirements of 37 CFR §1.98(a)(3), as a concise statement of relevance, as it is presently understood by the individual designated in 35 U.S.C. §1.56(c) most knowledgeable about the content of the information, the undersigned attorney of record submits a translation of portions of an official action by a foreign examiner in which the references were cited. The relevance to the pending U.S. patent application is that the references were cited in a foreign patent application on the same subject matter. However, no independent analysis of the reference, the accuracy of the statement of the foreign examiner or the claims of the foreign application under the laws of that country or the United States relative to the subject matter claimed in the present application has been made, the present understanding of the contents thereof by the undersigned being based on the translation of the foreign examiner's comments submitted herewith.

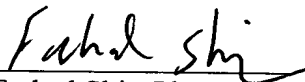
I hereby certify that each item of information contained in this Information Disclosure Statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this Information Disclosure Statement.

This citation does not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicant is aware.

It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Please charge any deficiencies in fees and credit any overpayment of fees to Attorney's Deposit Account No. 50-0481.

Respectfully submitted,


Farhad Shir, Ph.D.
Registration No. 59,403

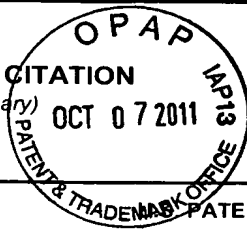
Date: 10/7/11

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INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)



ATTY DOCKET NO.

APPLICATION NO.

10/564,742

APPLICANT(S)

Daisuke ENDO, et al.

FILING DATE

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GROUP ART UNIT

1729

PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
	2002-151081	05/24/2002	Japan			ABS	
	2003-007299	01/10/2003	Japan			ABS	
	2003-197255	07/11/2003	Japan			ABS	
	2001-185153	07/06/2001	Japan			ABS	
	2000-323126	11/24/2000	Japan			ABS	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

			Japanese Office Action dated September 6, 2011 (with English translation).

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.